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## Supplementary Materials for

### **One-step vapor-phase synthesis of transparent high refractive index sulfur-containing polymers**

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## Supplementary Text

### X-ray reflectometry (XRR) analysis

The analysis method involves measuring the intensity of X-ray beam reflected on the sample with changing the incident angle of X-ray. In the XRR analysis, the refractive index of material can be estimated by the equation (1). When the incident angle is lower than the critical angle, incident X-ray beam is totally reflected and thus the reflectivity value becomes 1. Therefore, the critical angle is related to the refractive index of material, which can be calculated by the following equations (38).

$$n = 1 - \delta - i\beta \quad (1)$$

$$\delta = \left( \frac{r_e \lambda^2}{2\pi} \right) N_o \rho \sum_i x_i (Z_i + f_i') / \sum_i x_i M_i \quad (2)$$

$$\beta = \left( \frac{r_e \lambda^2}{2\pi} \right) N_o \rho \sum_i x_i (Z_i + f_i'') / \sum_i x_i M_i \quad (3)$$

$r_e$ : Classical radius of an electron ( $2.818 \times 10^{-9}$  m);  $N_o$ : Avogadro number;

$\lambda$ : X-ray wavelength;  $\rho$ : Density (g/cm<sup>3</sup>);  $Z_i$ : Atomic number of the  $i^{\text{th}}$  atom;

$M_i$ : Atomic weight of the  $i^{\text{th}}$  atom;  $x_i$ : Atomic ratio of the  $i^{\text{th}}$  atom;

$f_i'$ ,  $f_i''$ : Atomic scattering factor of the  $i^{\text{th}}$  atom

where  $\delta$  is the energy dispersive term, and  $\beta$  is X-ray absorption term.

The real part of the complex refractive index is related to the phase velocity of X-ray in the material, and the imaginary part is related to the X-ray absorption of the material. Therefore, the critical angle is related only to the real part of the complex refractive index, which can be calculated as follows.

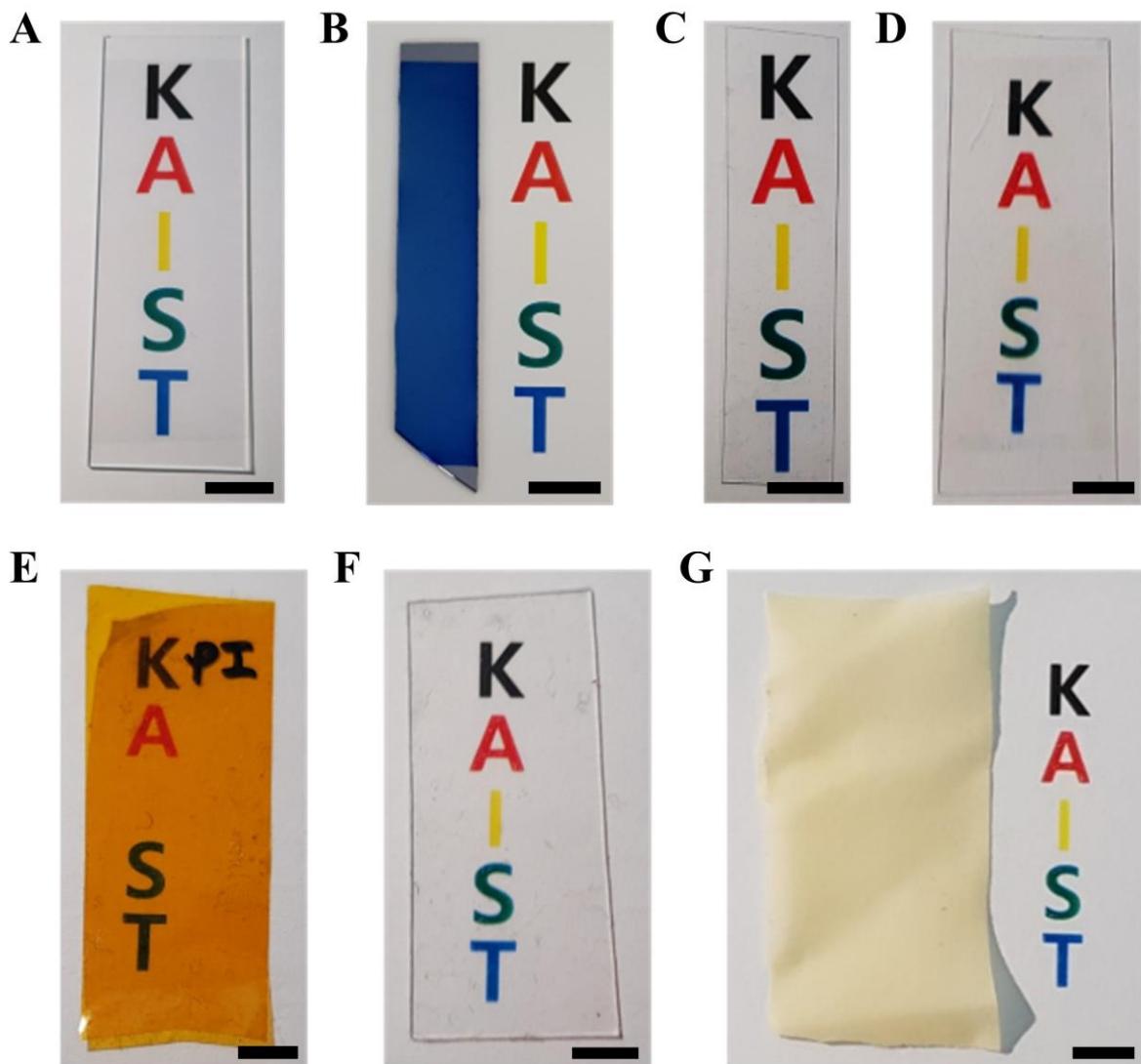
$$n = 1 - \delta = \cos(\theta_c) \doteq 1 - \frac{\theta_c^2}{2} \quad (4)$$

$$\theta_c \doteq \sqrt{2\delta} \quad (5)$$

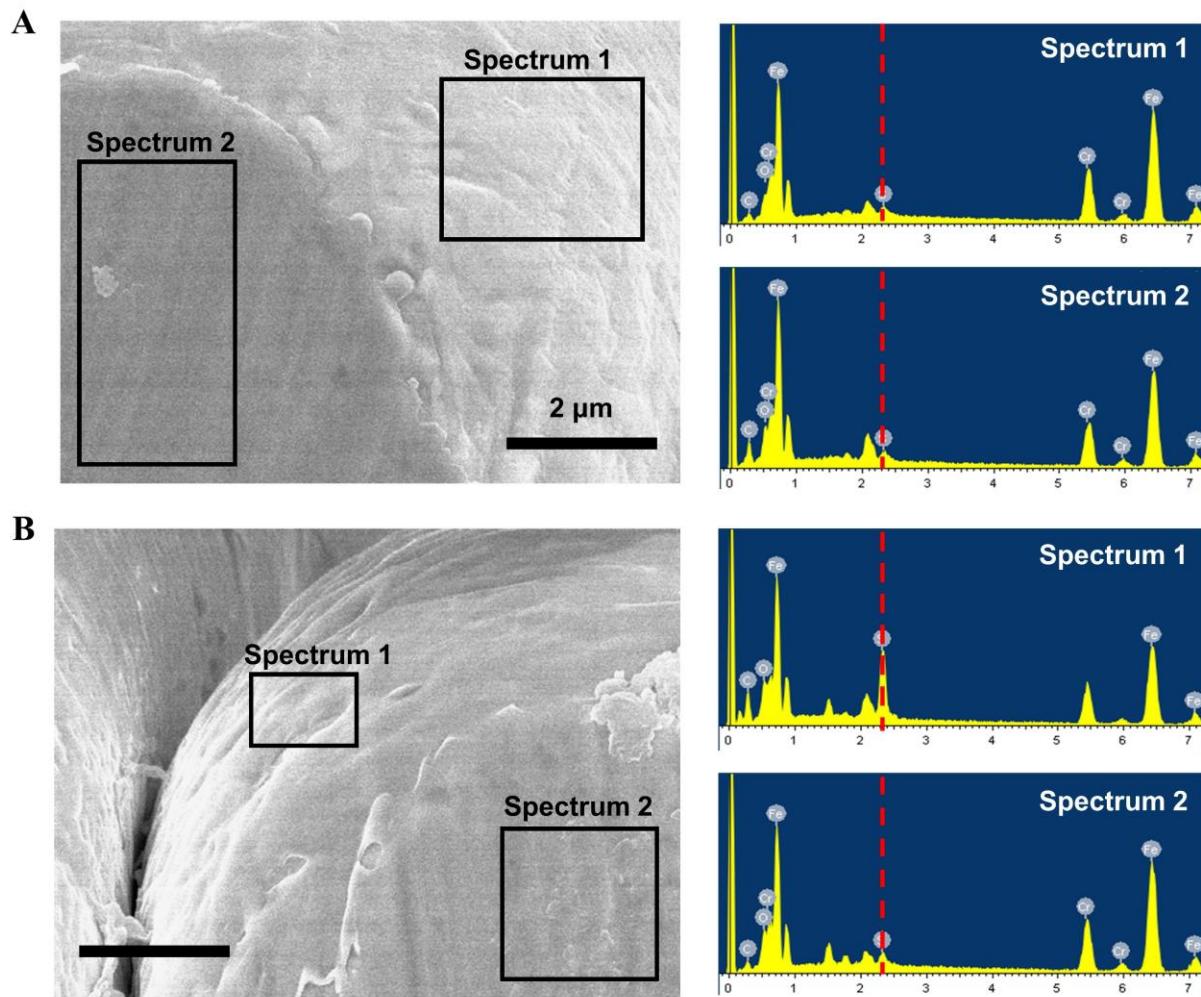
Since the  $\delta$  value includes the density information of the sample, which can be calculated from the critical angle value of the incident X-ray beam. In our data, the critical angle is  $0.35^\circ$ , which gives the density of SBDDVE as  $1.58 \text{ g/cm}^3$ .

#### *Conformal coating on complex structure*

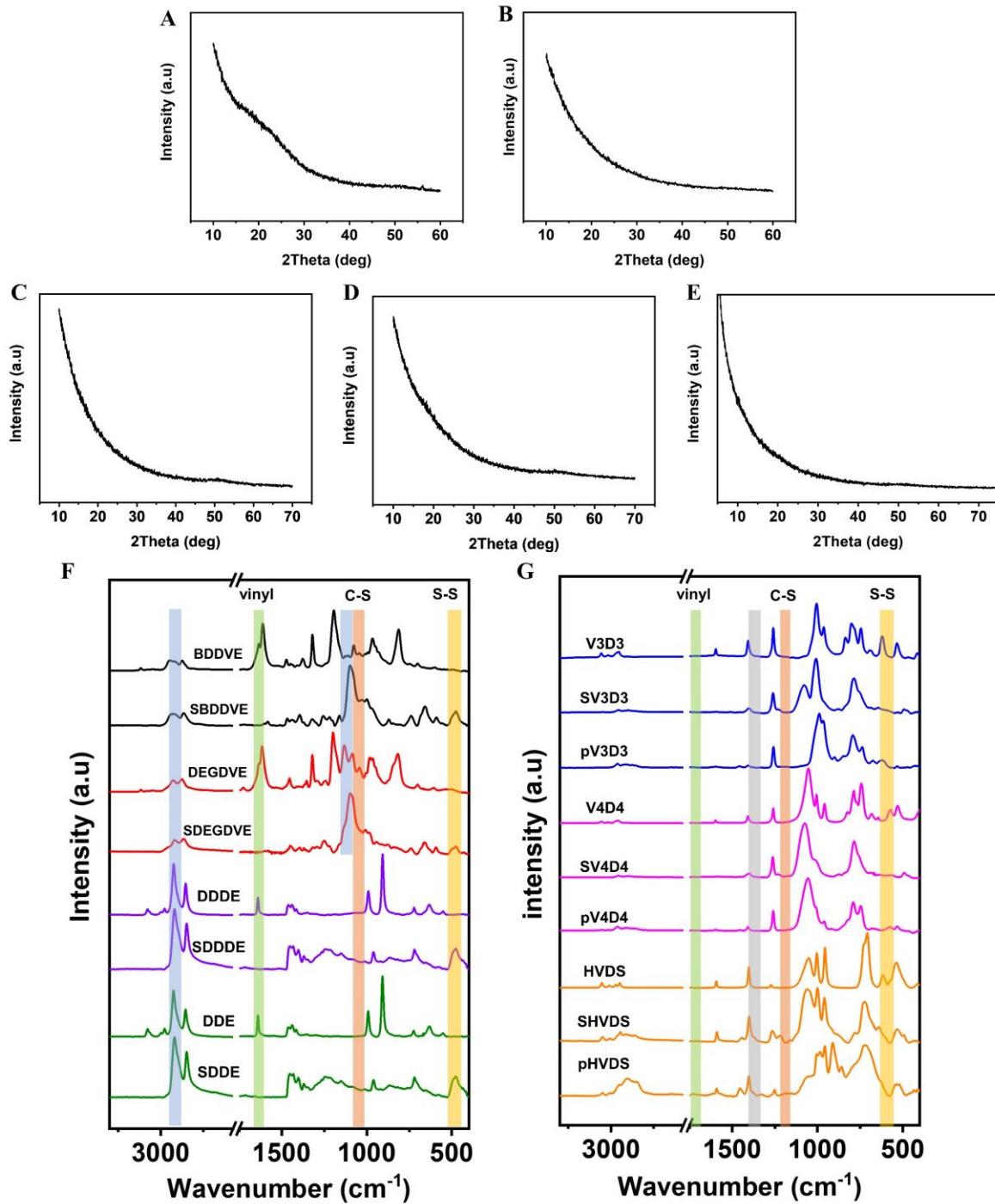
In the EDS spectra from the cross-sectional images in **Fig. S2**, bare stainless steel mesh shows only a trace amount of sulfur, while the stainless steel mesh coated with 200 nm-thick SBDDVE shows 9.43 wt% sulfur content at the side of the mesh fiber, which indicates deposition of SCP is accomplished.



**Fig. S1. SCP films on various substrates.** Digital camera images of the colorless poly(sulfur-*co*-1,4-butanediol divinyl ether) (SBDDVE) films (thickness = 110 nm), deposited on (A) glass, (B) silicon wafer, (C) polyethylene terephthalate (PET), (D) polyethylene naphthalate (PEN), (E) polyimide (PI), (F) polydimethyl siloxane (PDMS), and (G) latex. (Scale bar : 1cm) Photo credit: Wontae Jang (Korea Advanced Institute of Science and Technology).

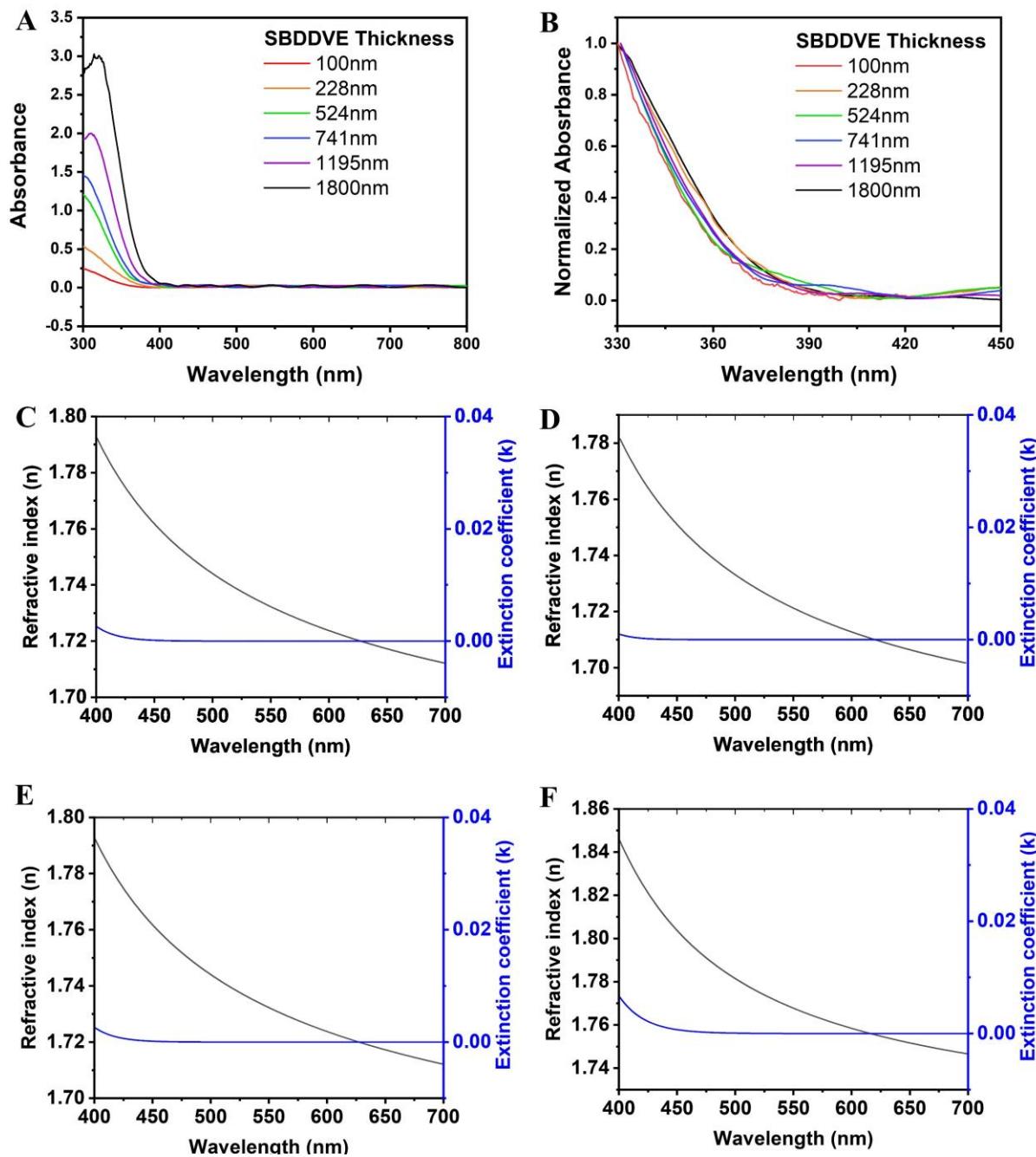


**Fig. S2.** Cross-sectional scanning electron microscope (SEM) image and energy dispersive spectroscopy (EDS) scan spectra with sulfur atom peaks (red dash line) of the stainless steel mesh coated with the sulfur-containing polymer (SCP) film (Spectrum 1) and the non-coated area (Spectrum 2) of (A) before and (B) after the 200 nm SBDDVE film deposition on the stainless steel mesh.

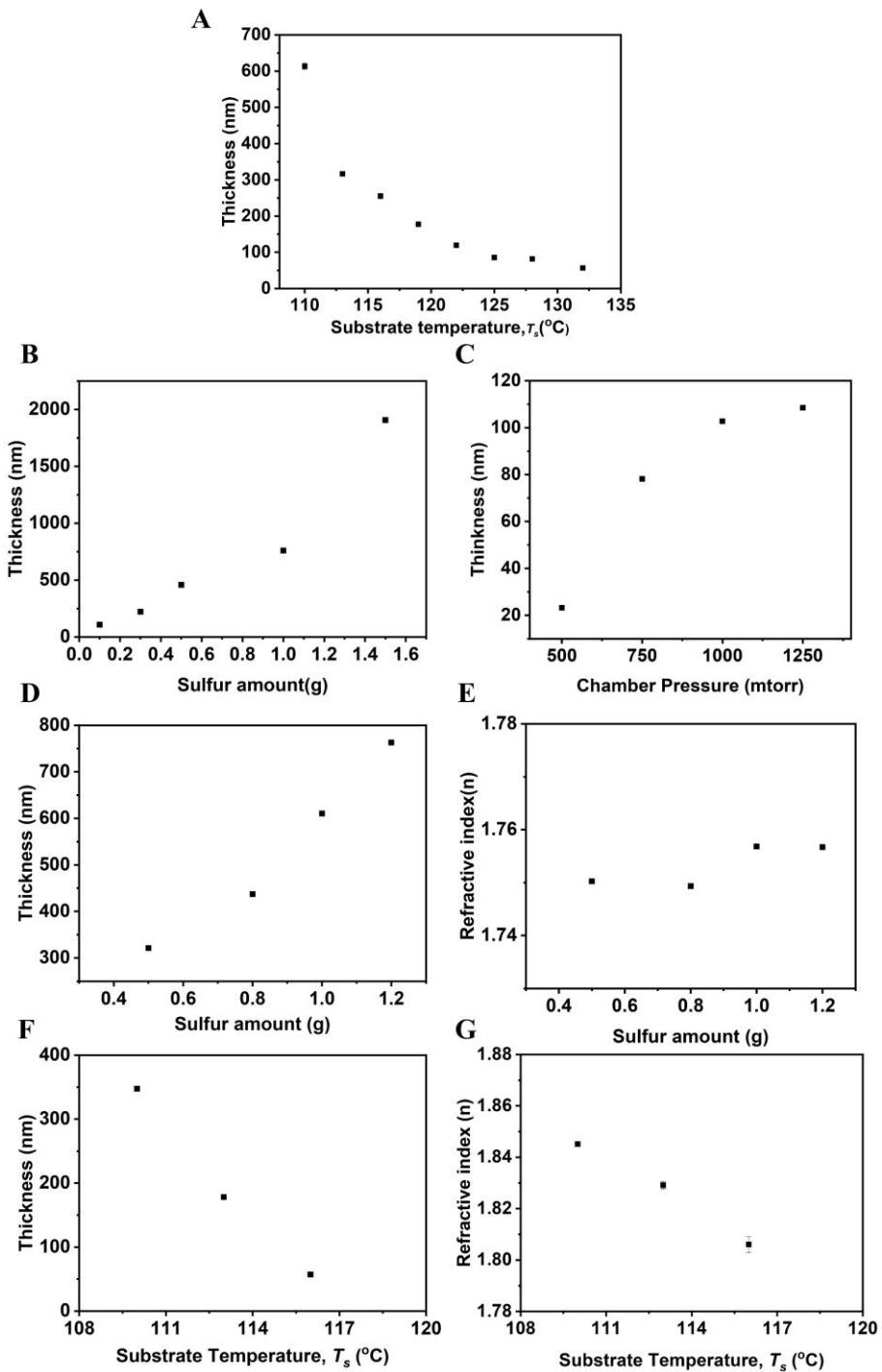


**Fig. S3. X-ray diffraction (XRD) spectra of (A) SBDDVE film with 61.64 wt% and (B) 66.82 wt% of sulfur contents; (C) SV4D4, (D) SV3D3, (E) SHVDS, deposited by sCVD, and Fourier transform infrared (FTIR) spectra of (F) 1, 4-butanediol divinyl ether (BDDVE), di(ethylene glycol)divinyl ether (DEGDVE), 1,11-dodecadiene (DDDE), 1,9-decadiene(DDE), and the SCPs of poly(sulfur-co-1,4-butanediol divinyl ether) (SBDDVE), poly(sulfur-co-di(ethylene glycol)divinyl ether) (SDEGDVE), poly(sulfur-co-1,11-dodecadiene) (SDDDE), poly(sulfur-co-1,9-decadiene) (SDDE) synthesized by sCVD, (G) 1,3,5-trivinyl-1,3,5-trimethylcyclotrisiloxane(V3D3), 1,3,5,7-tetravinyl-1,3,5,7-tetramethylcyclotetrasiloxane**

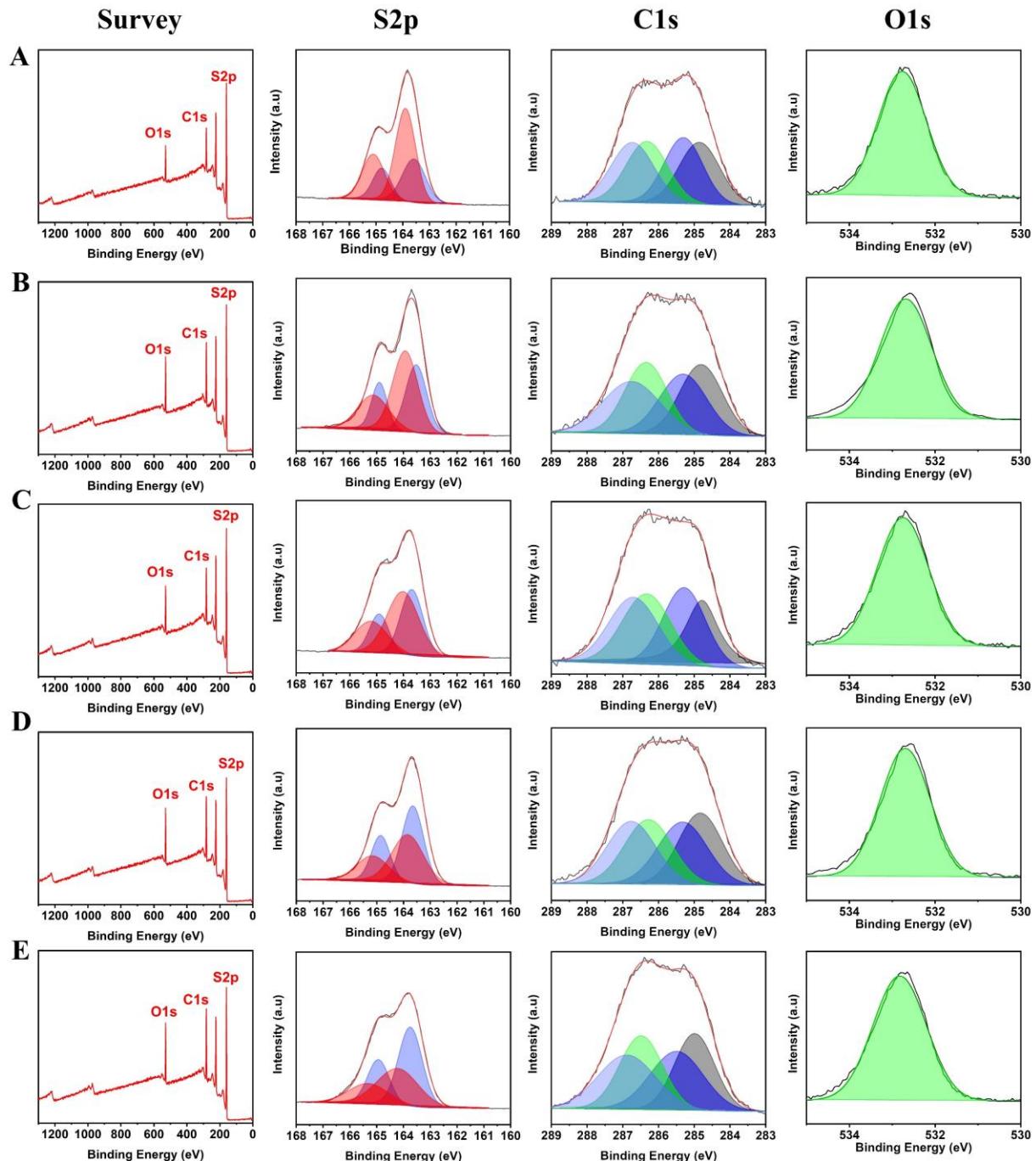
(V4D4), hexavinyldisiloxane (HVDS) monomer, and their corresponding polymers of poly(1,3,5-trivinyl-1,3,5-trimethylcyclotrisiloxane) (pV3D3), poly(1,3,5,7-tetravinyl-1,3,5,7-tetramethyl cyclotetrasiloxane) (pV4D4), poly(hexavinyldisiloxane) (pHVDS), and the SCPs of poly(sulfur-co-di(ethylene glycol)divinyl ether) (SDEGDVE), poly(sulfur-co-1,3,5-trivinyl-1,3,5-trimethylcyclotrisiloxane) (SV3D3), poly(sulfur-co-1,3,5,7-tetravinyl-1,3,5,7-tetramethylcyclotetrasiloxane) (SV4D4), and poly(sulfur-co-hexavinyldisiloxane) (SHVDS), synthesized by sCVD, where blue area at 1100, 2900  $\text{cm}^{-1}$  represent -C-O-C- and -C-H stretching peaks, respectively, and gray area at 1260  $\text{cm}^{-1}$  represents Si-CH<sub>3</sub> peak.



**Fig. S4.** UV-Vis absorbance (**A**) and normalized UV-Vis absorbance (**B**) spectra of SBDDVE films of varying thickness obtained from sCVD, and the refractive index ( $n$ ) and extinction coefficient ( $k$ ) values of (**C**) SV3D3, (**D**) SV4D4, (**E**) SDDDE, (**F**) SDDE obtained by ellipsometry measurement.

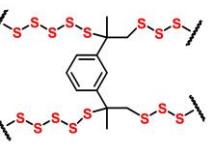
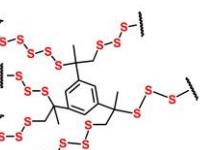
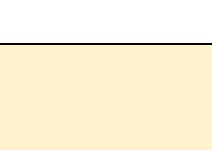


**Fig. S5.** Thickness variation of SBDDVE film with respect to (A) substrate temperature ( $T_s$ ) (B) the sulfur loading amount (with the fixed chamber pressure of 1000 mTorr and substrate temperature ( $T_s$ ) = 110  $^{\circ}$ C), (C) the chamber pressure (with the fixed sulfur amount 0.1 g and  $T_s$  = 110  $^{\circ}$ C), (D) Thickness, (E) refractive index variation of SBDDVE film with respect to sulfur loading amount (with the fixed chamber pressure of 1000 mTorr and  $T_s$  = 110  $^{\circ}$ C) with 120 min reaction time, (F) thickness, (G) refractive index variation of the substrate temperature (with the fixed sulfur loading amount of 0.3 g and the process pressure of 1000 mTorr).



**Fig. S6. X-ray photoelectron spectroscopy (XPS) survey spectra and deconvoluted S2p (left), C1s (center), O1s (right) XPS high resolution scan spectra of SBDDVE films with various sulfur contents of (A) 71.90 wt%, (B) 68.82 wt%, (C) 66.86 wt%, (D) 63.58 wt%, and (E) 61.69 wt%. Deconvoluted spectra are colored with light blue for S-C-O, green for C-O, blue for C-S, and grey for C-C in C1s XPS high resolution spectra, blue for C-S and red for S-S, respectively, in S2p XPS high resolution spectra, and green as C-O in O1s XPS high resolution spectra.**

**Table S1.** Comparison of SCPs from sCVD with those synthesized by other methods. Tristan S. Kleine (University of Arizona) and Wontae Jang (Korea Advanced Institute of Science and Technology).

Material	$n_{632.8\text{nm}}$	Color	Notes	Ref
		1.87 Yellow/ Red	<ul style="list-style-type: none"> <li>Synthesized by inverse vulcanization</li> <li>Must use olefin monomer miscible with elemental sulfur</li> <li>A strong absorption in visible region</li> <li>Hard to mold into thin film due to the lack of solubility in common organic solvents.</li> </ul>	1
		1.83 Orange/ Red	<ul style="list-style-type: none"> <li>Synthesized by inverse vulcanization</li> <li>Use of sulfur and olefin comonomer with tri-vinyl groups</li> <li>A strong absorption in visible region</li> </ul>	6
		1.78 Yellow	<ul style="list-style-type: none"> <li>Multi-step synthesis.</li> <li>Tellurium was used to maximize the refractive index.</li> <li>A strong absorption in visible region</li> </ul>	39
<b>This study</b>	> 1.90	Colorless	<ul style="list-style-type: none"> <li>One-step sCVD in vapor phase.</li> <li>No limit in monomer selection.</li> <li>Fully transparent in whole visible region.</li> <li>Film thickness and refractive index properties can be controlled in systematic manner.</li> <li>Extremely high refractive index larger than 1.9.</li> </ul>	

**Table S2.** Refractive index from ellipsometry measurement, and calculated Abbe's number ( $\nu_D$ ) of the SBDDVE films with two different refractive index, SDDDE, SDDE, SV3D3, and SV4D4 synthesized by sCVD.

Polymer	$n_{632.8}$	$n_{656.3}$	$n_{589.3}$	$n_{486.1}$	$\nu_D$
SBDDVE	1.915	1.910	1.926	1.973	14.698
	1.726	1.724	1.732	1.755	23.613
SDDDE	1.719	1.717	1.725	1.748	23.387
SDDE	1.754	1.751	1.760	1.787	21.111
SV3D3	1.729	1.726	1.737	1.767	17.976
SV4D4	1.708	1.706	1.714	1.738	22.313

**Table S3.** XPS survey scan quantitative result of SBDDVE films with various sulfur weight % (wt%), copolymer ratio, and S-S/S-C bond ratio.

Sulfur wt%	Atomic %			Copolymer ratio	S-S/S-C ratio
	S	C	O	$S_8 : BDDVE$	
71.90	52.81	37.24	9.95	1.42 : 1	1.84
68.82	48.48	39.63	11.88	1.22 : 1	1.45
66.86	46.21	41.31	12.49	1.12 : 1	1.24
63.58	43.23	44.68	12.09	0.97 : 1	0.94
61.69	41.46	46.44	12.09	0.89 : 1	0.79

\* Considered Molecular weight of  $S_8$  is 256.52, and BDDVE is 142.2

**Table S4.** XPS S2p, C1s high resolution scan quantitative result of SBDDVE films with various sulfur weight % (wt%), calculated S-C bond ration in total polymer, and S-S/S-C bond ratio

Sulfur wt%	S2p deconvoluted area (a.u.)				S-C bond ratio in total polymer (%)	S-S/S-C ratio
	C-S 2p <sub>1/2</sub>	C-S 2p <sub>3/2</sub>	S-S 2p <sub>1/2</sub>	S-S 2p <sub>3/2</sub>		
71.90	8323.85	16647.69	16324.03	32648.06	17.83	1.96
68.82	13192.70	26385.40	18700.00	37400.00	20.05	1.42
66.86	13628.79	27257.58	18591.42	37182.83	19.54	1.36
63.58	15622.28	31244.56	14174.77	28349.55	22.66	0.91
61.69	16201.22	32402.44	12762.19	25524.38	23.19	0.79

Sulfur wt%	C1s deconvoluted area (a.u.)				S-C bond ratio in total polymer (%)
	S-C-O	C-O	C-S	C-C	
71.90	7341.494	7381.83	7229.488	7255.087	18.58
68.82	12404.24	11721.76	12283.53	12036.01	20.20
66.86	12631.49	13623.93	13757.76	13140.88	20.51
63.58	14222.58	13890.16	13877.22	13602.36	22.58
61.69	13843.02	14036.51	14196.76	14008	23.22

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